Reg. No. :

Question Paper Code : 70424

B.E./B.Tech. DEGREE EXAMINATIONS, NOVEMBER/DECEMBER 2021.

Second Semester

Electronics and Communication Engineering

EC 6201 — ELECTRONIC DEVICES

(Regulations 2013)

(Also Common to PTEC 6201 – Electronic Devices for B.E.(Part-Time) – First Semester – Electronics and Communication Engineering – Regulations 2014)

Time : Three hours

Maximum : 100 marks

Answer ALL questions.

PART A — $(10 \times 2 = 20 \text{ marks})$

- 1. Determine the built in potential in a silicon PN junction with $N_a = 10^{15}$ cm⁻³, $N_D = 2 \times 10^{16}$ cm⁻³, $n_i = 1.5 \times 10^{10}$ cm⁻³ at T = 300K.
- 2. What do you understand by "Hyper abrupt" junction?
- 3. The common emitter gain of a BJT, $\beta = 450$. Calculate the emitter current, if the collector current is 1 mA.
- 4. What is the need for multi emitter bipolar transistor?
- 5. Calculate the flat band voltage for a MOS device with $\phi_{ms} = 0.96$, N_{oc} = $10^{14}/m^2$ and C_{ox} = 1.15×10^{-3} F/m².
- 6. Determine the resistance of a MOSFET operating in the linear region with $\beta = 1.75 \times 10^3$, $V_{GS} = 5V$ and $V_T = -2.5V$.
- 7. Calculate the space charge width for a metal semiconductor junction having $\varepsilon_r = 11.7$, $\varepsilon_0 = 8.854 \times 10^{-14}$, $V_{bi} = 0.67V$, $N_d = 7 \times 10^{18}$ at zero bias.
- 8. State the principle of Light dependent resistor.
- 9. Define intrinsic standoff ratio of an UJT.
- 10. Silicon is a preferred material for solar cell Justify.

PART B — $(5 \times 16 = 80 \text{ marks})$

- 11. (a) (i) Explain the basic structure of PN junction with diagrams illustrating doping profile and space charge regions. (8)
 - (ii) From the basic principles, derive an expression for the built in potential barrier in a PN junction.
 (8)

Or

- (b) (i) Draw the band diagram of a PN junction under reverse bias and derive an expression for the maximum electric field in the PN junction. (10)
 - (ii) Explain the switching behavior of PN junction diode from forward to reverse bias, with diagrams illustrating minority carrier concentration and current characteristics during switching.
 (6)
- 12. (a) (i) Discuss the current density components of a NPN bipolar transistor operating in active mode. (10)
 - (ii) Explain the input and output characteristics of a NPN transistor in CE mode.
 (6)

Or

- (b) (i) From the basic principles, deduce the expressions for Ebers Mall equations for a bipolar transistor and also draw the basic Ebers -Moll equivalent circuit. (10)
 - (ii) Compare the features of Ebers Moll and Gummel Poon models. (6)
- 13. (a) (i) Explain the basic JFET structure and principle of operation with relevant diagrams. (10)
 - (ii) Deduce an expression for drain current in the case of JFET. (6)

Or

- (b) (i) Explain the various regions of operation of a MOSFET with relevant diagrams. (10)
 - (ii) Discuss about channel pinch off and velocity saturation in MOSFETs.
 (6)
- 14. (a) (i) Enumerate the characteristics of a metal semiconductor junction under forward and reverse bias with necessary band diagrams. (10)
 - (ii) Explain Schottky effect in metal dielectric interface. (6)

Or

- (b) (i) Compare the characteristics of Silicon and Gallium Arsenide. (6)
 - (ii) Outline the principle and operation of a laser diode. (10)

15.	(a)	(i)	Discuss the construction, operating principle of a Silicon contr rectifier and its characteristics.	olled (10)
		(ii)	Compare the features of SCR and TRIAC.	(6)
			Or	
	(b)	(i)	Explain the carrier generation in solar cells using relevant	band

- (i) Explain the carrier generation in solar cens using relevant band diagrams.
 (6)
 (ii) List the basic differences between solar cell and photo diode.
 (4)
- (iii) Brief about the principle of charge coupled device. (6)